



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 5520**
Hiroki MAEDA et al. : Attorney Docket No. 2006_0043A
Serial No. 10/565,104 : Group Art Unit 1753
Filed January 19, 2006 : Examiner Anca Eoff
PHOTOSENSITIVE RESIN COMPOSITION : MAIL STOP: AMENDMENT
AND METHOD OF FORMING A PATTERN
USING THE COMPOSITION

RESPONSE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO 23-0975

Sir:

In response to the Official Action dated July 16, 2007, the period for response having been extended for two months by the attached Petition, please amend the present application as follows: